

Title (en)

CONTROLLABLY DEGRADABLE COMPOSITION OF HETEROATOM CARBOCYCLIC OR EPOXY RESIN AND CURING AGENT

Title (de)

KONTROLLIERT ABBAUBARE ZUSAMMENSETZUNG BASIEREND AUF EINEM HETEROATOM-CARBONSÄURE- ODER EPOXY-HARZ UND EINEM HÄRTUNGSMITTEL

Title (fr)

COMPOSITION DONT LA DEGRADATION EST REGULABLE, A BASE DE RESINE EPOXY OU CARBOCYCLIQUE D'HETEROATOM ET A BASE D'UN AGENT DE DURCISSEMENT

Publication

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Application

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Priority

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- US 21047000 P 20000609

Abstract (en)

[origin: WO0079582A1] A reworkable underfilling sealing material (33) for the attachment of a semiconductor device (32) to a carrier substrate (31) is prepared from a composition comprising a curable resin (a) which is a resin with a (thio)ether or carbonate core structure and a heteroatom-containing carbocyclic structure, an epoxy resin having at least one alkylene oxide residue, or an epoxy resin with a monoperoxide (thio)ester or carbonate coreactant diluent; and (b) a curing agent including a polyamine, an epoxy- or novolac-modified amine, an amide compound or an imidazole; optionally with an anhydride.

IPC 1-7

H01L 21/56; H01L 21/58; C08K 3/36; C08L 63/00; C08L 69/00; C08L 71/00

IPC 8 full level

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CPC (source: EP KR)

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